

Carriers in Semiconductor

Thursday, November 5, 2020 12:01 AM

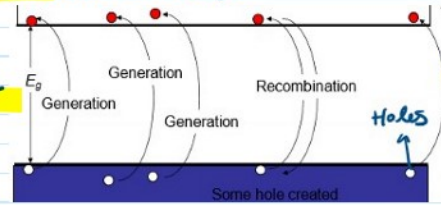
Electron & hole concentration

2.4.1 Intrinsic Case

- Properties of pure material \rightarrow intrinsic to that material
- intrinsic concentration of e^- in VB = intrinsic concentration of e^- in CB

$$n_i = p_i \rightarrow i = \text{intrinsic}, n = e^- \text{ concentration}, p = \text{hole concentration}$$

- holes in VB & e^- in CB
- n_i, p_i depends on E needed to break band (E_g) & T
- $n_i = B(T) \exp\left(\frac{-E_g}{2kT}\right) \rightarrow B(T) = \text{material}$



- Increase Conductivity:
 - Add carriers
 - Add elements that add e^- to CB or remove e^- from VB

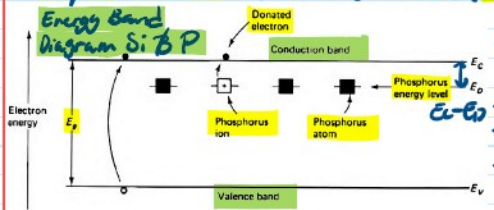
2.4.2 Extrinsic Case

- Semiconductors doped w/ impurities have n & p concentrations diff. than in pure materials

ex. Doping P in Si: P \rightarrow donor

- extra e^- donated to CB of doped Si can conduct

- Dopant atom becomes $+$ ion (fixed in place)



- Add P in Si lattice $\rightarrow E_D @ 0.044 \text{ eV below CB} \rightarrow E_C - E_D \rightarrow E$ needed to donate e^-
- $E_C - E_D$ - excitation of extra $e^- \rightarrow e^-$ in CB & p ion $^+$

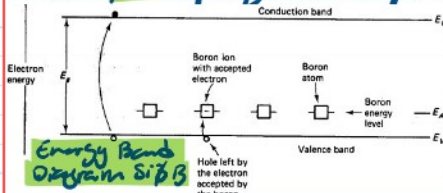
- ions = fixed & not conductive
- extra $e^- \uparrow n \rightarrow$ majority carrier

\rightarrow carrier (e^-) charged, SC material doped = n-type (n-doping)

\rightarrow P & As = group V & B = group III donors to dope Si \rightarrow creates e^-

- For n-doping Si: group V \rightarrow P, As \rightarrow Donors

- For p-doping Si: group III \rightarrow B \rightarrow Acceptors



- 3 V e^- B
- \rightarrow B \rightarrow ion $^+$

- creates holes

- extra holes $\uparrow p \rightarrow$ majority carrier

2.4.3 Charge Neutrality

- If no E field, charge density = 0 \rightarrow electrically neutral

\rightarrow intrinsic: $n_i = p_i$

\rightarrow extrinsic: $n + N_A^- = p + N_D^+ \rightarrow N_D = \text{conc. donor atom impurity}, N_D \neq N_D^+ \rightarrow (-) \text{ charge}$
 $N_A = \text{conc. acceptor atom impurity}, N_A \neq N_A^- \rightarrow (+) \text{ charge}$

- If $N_D^+ = N_A^-$, $n = p \rightarrow$ intrinsic (compensated)

2.4.3 Dynamic Equilibrium

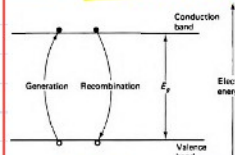
- Absorbed E \rightarrow bands break \rightarrow Generate e^- & holes \rightarrow Recombination = Thermal Equilibrium

- Recombination depends on T & n, p

\rightarrow Recombination rate in extrinsic = intrinsic: $n_0 p_0 = n_i p_i$

$\therefore n_i = p_i$, $n_0 p_0 = n_i^2 \rightarrow n_i$ is known in Si @ 20°C : $n_i = 10^{10} \text{ cm}^{-3}$

$\rightarrow p$ until recombination rate \rightarrow equilibrium



- If doping lvl of a dopant \gg other dopant or only 1 dopant used & its conc. $\gg n_i$

$n_0 = N_D^+$ for n-doped, $p_0 = N_A^-$ for p-doped

If both n & p dopants used: $p_0 = \frac{(-N_D^+ + N_A^-) \pm \sqrt{(N_A^- - N_D^+)^2 + 4n_i^2}}{2}$

@ RT: $N_A = N_A^-$, $N_D = N_D^+ = n_0$

- Majority/Minority Carriers

$N_D^+ > N_A^-$: n-type material $\rightarrow e^- = \text{maj}$, holes = min

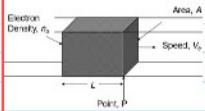
$N_A^- > N_D^+$: p-type material \rightarrow holes = maj, $e^- = \text{min}$



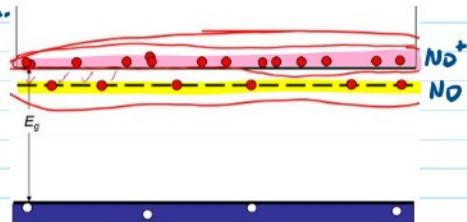
Permanent & mobile like

$N_A > N_D$: p-type material \rightarrow holes $= n_A$, $e^- = n_B$

Current & Mobility



- time τ to move L
- avg speed e^- moves: $v_{drift} = \frac{L}{\tau}$
- change in the box $= n_0 A L e$
- current $= \frac{-n_0 A L e}{\tau}$



Current Density $J = n_0 q e v_e = -n_0 q e v_e$

electron speed: $v_e = \mu E \rightarrow \mu = \frac{e \tau_{collision}}{m^*}$

electron density: $j = \frac{-n_0 e^2 \tau_{coll} E}{m^*} = n_0 \mu e E$

conductivity: $j = \sigma E = n_0 q \mu E \rightarrow \sigma = n_0 q \mu$

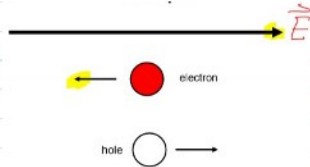
Ohm's Law

- $V = IR$

- $JA = I = \sigma EA \rightarrow E = -\frac{\Delta V}{\Delta L}$

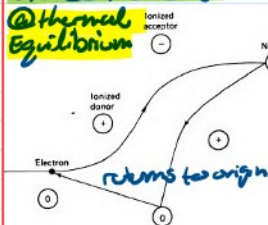
- $R = \frac{\Delta L}{\sigma A}$

- E Field: $F = q E$



Drode Model

@ thermal Equilibrium



- conductivity \propto to p in VB & n in CB,

$\sigma = (q \mu_n n_0 + q \mu_p p_0)$

- \uparrow eff mass $\rightarrow \downarrow v_{avg}$

- \uparrow doping level \downarrow mobility, $\downarrow T \downarrow$ mobility

- \uparrow carriers $\uparrow T$

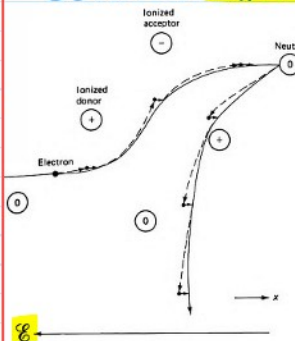
- Drode Model Fails at high fields \rightarrow drift saturating or \downarrow w/ $\uparrow E$

- collisions b/w e^- & ions & atoms @ lattice

- e^- motion randomized by collisions, random motion \rightarrow no current

- when atoms in material absorb thermal E & vibrate in lattice atom spacing \rightarrow perturbed

- Quanta of lattice vibrational $E =$ phonon



- e^- drifts, path of e^- displaced to right $\rightarrow e^-$ drift due to field E

- e^- does not return to origin like @ equilibrium